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Electronic Version v1.1

Stylesheet Version v1.1.0

Title of Invention	ENDPOINT DETECTION IN CHEMICAL-MECHANICAL POLISHING OF PATTERNED WAFERS HAVING A LOW PATTERN DENSITY
Application Number :	
Date :	
First Named Applicant:	Xinhui Wang
Confirmation Number:	
Attorney Docket Number:	FIS920030031

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Documents being submitted:	Files
us-fee-sheet	FIS920030031-usfees.xml us-fee-sheet.xsl us-fee-sheet.dtd
us-ids	FIS920030031-usidst.xml us-ids.dtd us-ids.xsl
us-request	FIS920030031-usrequ.xml us-request.dtd us-request.xsl
us-declaration	FIS920030031DEC2.tif
us-declaration	FIS920030031DEC3.tif
us-declaration	FIS920030031DEC4.tif
application-body	FIS920030031-trans.xml us-application-body.xsl application-body.dtd wipo.ent mathml2.dtd mathml2-qname-1.mod isoamsa.ent isoamsb.ent isoamsc.ent isoamsn.ent isoamso.ent isoamsr.ent isogrk3.ent isomfrk.ent isomopf.ent isomscr.ent isotech.ent isobox.ent isocyr1.ent isocyr2.ent isodia.ent isolat1.ent isolat2.ent isonum.ent isopub.ent mmlextra.ent mmlalias.ent soextblk.dtd FIS920030031dwg1.tif FIS920030031dwg2.tif FIS920030031dwg3.tif FIS920030031dwg4.tif FIS920030031dwg5.tif
us-declaration	FIS920030031DEC1.tif
Comments	
Assignee Name: International Business Machines Corporation, Assignee Residence: Armonk, NY 10504	